

**POLISHING COMPOSITION CONTAINING HYBRID ABRASIVE FOR NICKEL-
PHOSPHOROUS COATED MEMORY DISKS**

ABSTRACT

The invention provides a polishing composition that contains (a) an abrasive
5 comprising (i) first alpha alumina particles that have an average aspect ratio of 0.8:1 to 1.2:1,
(ii) second alpha alumina that have an average aspect ratio of greater than 1.2:1, (iii) fumed
alumina particles, and (iv) wet-process silica particles, and (b) water. The invention also
provides a method of polishing a substrate, especially a nickel-phosphorous substrate, with
the polishing composition.

10 (Fig 1)